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Thin Solid Films 373 (2000) 299–300

thin solid films

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Author Index of Volume 373

Aceves, M., 134
Acquaviva, S., 266
Albella, J.M., 277
Alvarez-Fregoso, O., 293
Alves, E.J., 287
Andrade, E., 129, 180
Anopchenko, A., 216
Araujo-Osorio, J., 122
Asakawa, K., 170
Azucena-Coyotécatl, H., 227

Balderas-Navarro, R.E., 207
Ballesteros, C., 113
Baur, K., 222
Becerril, F., 293
Benacka, S., 129
Bernal, R., 1
Bonanni, A., 41
Brennan, S., 222
Brunel, M., 216

Caballero-Briones, F., 6
Calleja, W., 134
Calzada, L., 98
Camps, E., 255, 293
Carbajal-Franco, G., 141
Carranza, J., 134
Carreño, M.N.P., 273
Carrillo, J., 134
Casalboni, M., 150
Castillo, S.J., 10
Castro-Rodríguez, R., 6, 23
Cerdeira, A., 176
Chan, C.C., 84
Chang, D.Hoon., 53
Cheang-Wong, J.C., 117, 129
Chromik, S., 129
Chung, C.K., 68
Contreras-Puente, G., 235
Cruz, F., 235
Cruz, L.R., 15
Cruz-Vázquez, C., 1

Díaz-Valdés, E., 117, 122
de Andrés, A., 94, 98
de Avillez, R.R., 15
De Matteis, F., 150
Dellera, F., 261
Domínguez, J.M., 141
Dong, J., 19

Eberl, K., 164
Ernst, F., 164
Escobar-Alarcón, L., 255
Espinoza-Beltrán, F.J., 1, 10
Esteve, J., 282
Estrada L., W., 137
Estrada, M., 176

Falcony, C., ix, 129, 134
Falcony-Guajardo, C., 122
Ferrieu, F., 211
Fotakis, C., 266
Fuentes-Cabrera, M., 19
Fundora, A., 60

Gago, R., 277
Galindo, H., 247, 282
García-Hernández, M., 94, 98
García-Rocha, M., 41
Ghezzi, F., 261
Giampaolo, C., 195, 195
Gilabert, U., 28
Gómez, M.E., 113
González-Hernández, J., 10, 184
Gould, R.D., 89
Grigorieva, N.R., 227
Guillén-Cervantes, A., 159
Guimpel, J., 102
Guinea, F., 94

Hando, T., 251
Hanic, F., 129
Hernández-Calderón, I., 159
Hingerl, K., 41
Hirata, G.A., 49
Hoffmann, H., 107
Holý, V., 216
Honda, T., 199
Horng, R.H., 84, 231
Hrach, R., 203
Huerta-Ruelas, J., 239
Hwang, J., 68

Inoue, M., 1
Inoue, M.B., 1
Iribarren, A., 6
Ishikawa, T., 170

Jaw, T.H., 68
Jergel, M., ix, 117, 122, 129, 129, 216
Jiménez, I., 277
Jimenez, S., 129

Kang, S.Jun., 53
Kazennov, B.A., 227
Kerner, J., 222
Kienzle, O., 164
Kinoshita, H., 251
Kivilahti, J.K., 64
Klini, A., 266
Kohmoto, S., 170
Kryshtab, T.G., 79

Lastras-Martínez, A., 207
Lastras-Martínez, L.F., 207
Laurila, T., 64
Lee, M.K., 231
López, L.L., 49
López-López, M., 33, 159
Lopez-Lopez, M., ix
López-López, M., 37, 239
López-Luna, E., 159
Luby, S., 216
Luches, A., 216
Luyo-Alvarado, J., 37
Lytvyn, O.S., 79
Lytvyn, P.M., 79

Maciel, H.S., 243
Madrigal-Melchor, J., 227
Mae, K., 199
Mahmood, A., 180
Majková, E., 216
Mansano, R.D., 243
Martinez, E., 282
Martino, M., 216
Martín, J.I., 113
Martín, L., 98
Martínez, G., 10
Martínez, J.L., 94, 98
Massi, M., 243
McKittrick, J., 49
Meléndez-Lira, M., 37
Melendez-Lira, M., ix
Méndez, V.H., 37
Méndez-García, V.H., 33
Mendoza-Galván, A., 10
Miki-Yoshida, M., 137
Minami, T., 145, 189
Miyata, T., 145, 189
Molarius, J., 64
Momose, K., 33
Morales, A., 117
Morales, F., 122
Morales, J., 137
Morales-Acevedo, A., 235
Moyano, E., 28
Muhl, S., 180, 255, 293
Muñoz, A., 94
Muñoz-Martín, A., 98

Nakatani, T., 145
Nakatsuka, O., 73
Nikl, M., 195, 195
Nishimura, T., 170
Nitsch, K., 195, 195
Nogueira, P.M., 243
Novák, S., 203
Novikov, B.V., 227

Ojima, K., 33
Olea, O., 255
Oliva, A.I., 6
Otani, C., 243

P. Hernández, M., 23
Palacios Gomez, J., 79
Paraguay D., F., 137
Peña, J.L., 6, 23
Pereyra, I., 176, 273
Pérez Centeno, A., 33
Pérez-Roblez, J.F., 184
Pérez-Rodríguez, F., 227
Perrone, A., 266
Perrone, M.Rita., 155
Phani, A.R., 195, 195
Pianetta, P., 222
Piegari, A., 155
Pizzoferrato, R., 150
Portelles, J., 49
Prieto, C., 94, 98
Prieto, P., 113, 247, 282
Prosposito, P., 150
Protopapa, M. Lucia., 155

Ramirez-Rosales, D., 184
Ramírez, A., 46
Ramírez-Bon, R., 10
Rebouta, L., 287
Regolini, J.L., 211
Ribot, P., 211
Rincon, C., 282
Rincón, C., 247
Rivera-Alvarez, Z., 159
Rockett, A., ix
Rosales, P., 134

Sánchez, N.A., 247
Sánchez-Juárez, A., 141
Sancrotti, M., 261
Sankey, O.F., 19
Sansores, L.E., 180
Santana, G., 235
Santana-Aranda, M.A., 37
Santucci, S., 195, 195
Scarpettini, A., 28
Schmid, M., 41
Schmidt, O.G., 164
Sel'kin, A.V., 227
Shafai, T.S., 89

PII: S0040-6090(00)01457-7

Shmayda, W.T., 261
Singh, A., 222
Siqueiros, J.M., 49, 60
Sirena, M., 102
Sitter, H., 41
Sobotka, M., 203
Solis, J., 137
Somma, F., 195, 195
Sosa, V., 6
Sotelo-Lerma, M., 10
Soto, S., 176
Spasova, M., 216
Steren, L., 102
Stifter, D., 41
Štrbík, V., 129
Suni, I., 64

Takahashi, J., 251
Tamura, M., 33
Tavares, C.J., 287
Tiburcio-Silver, A., 141
Toda, Y., 189
Trigubó, A.B., 28

Vaillant, L., 235
Vargas, R., 117
Vazquez, L., 94
Vélez, M., 113
Verdonck, P., 243
Vicent, J.L., 113
Vidal, M.A., 37
Vigil, O., 235
Vilcarromero, J., 273
Villagrán, M., 293

Wang, J., 222
Werho, D., 222
Wu, L.H., 231
Wuu, D.S., 68, 84, 231

Yamamoto, T., 189
Yáñez-Limón, J.M., 184
Yasuda, Y., 73
Yonezu, H., 33, 37
Yoon, Y. Sup., 53

Zaima, S., 73
Zambom, L.S., 243
Zambrano, G., 247, 282
Zamorano-Ulloa, R., 184
Zapata-Torres, M., 23
Zehe, A., 46
Zelaya, O., ix
Zelaya-Angel, O., 239
Zeng, K., 64
Zocco, A., 266

ELSEVIER

Thin Solid Films 373 (2000) 301–306

thin solid films

www.elsevier.com/locate/tsf

Subject Index of Volume 373

Adhesion
Mechanical and tribological properties of tungsten carbide sputtered coatings, 282
AFM
Observation of thermal desorption and MBE growth rate using laser light scattering, 239
Aluminium electrodes
Conduction in lead phthalocyanine films with aluminium electrodes, 89
Amorphous hydrogenated carbon
Effects of the methane content on the characteristics of diamond-like carbon films produced by sputtering, 243
Amorphous materials
High deposition rate a-Si:H layers from pure SiH_4 and from a 10% dilution of SiH_4 in H_2, 176
Electrical conductive hard-carbon (diamond-like carbon) films formed by i-C_4H_{10}/N_2 supermagnetron plasma chemical vapor deposition method, 251
Annealing
Structural, optical and electrical characterization of In/CdS/glass thermally annealed system, 10
The influence of TiB_2-thin film thickness on metal–GaAs structural characteristics, 79
Atomic force microscopy
The influence of TiB_2-thin film thickness on metal–GaAs structural characteristics, 79

Ba–Ca–Cu–(O, F) precursors
Preparation and properties of precursor Ba–Ca–Cu–(O, F) thin films deposited from fluorides for superconducting Tl- and Hg-based films, 129
Band structure
Theoretical study of the structural, electronic and vibrational properties of $CdIn_2Te_4$, 19
Bi-based thin films
Rutherford backscattering analysis of Bi-based superconducting films, 117
Boron nitride thin films
Mechanical properties of boron nitride thin films obtained by RF-PECVD at low temperatures, 273

Cadmium sulfide
Strain gradients in polycrystalline CdS thin films, 6
Structural, optical and electrical characterization of In/CdS/glass thermally annealed system, 10
Cadmium telluride
The formation of CdTe thin films by the stacked elemental layer method, 15
$(CdTe)_{1-x}(In_2Te_3)_x$ pseudo-binary in polycrystalline CdTe–In films, 23
Carbides
Boron–carbon–nitrogen compounds grown by ion beam assisted evaporation, 277
Mechanical and tribological properties of tungsten carbide sputtered coatings, 282
Carbon
Electron evaporation of carbon using a high density plasma, 255
CdTe/InSb
Observation of thermal desorption and MBE growth rate using laser light scattering, 239
Cobalt
Structure of Ag/Co multilayers on excimer laser irradiation, 216
Composite films
Study of morphology of composite films, 203
Copper
Electrical and spectroscopic properties of amorphous copper sulfide films treated with iodine, lithium iodide and sodium iodide, 1
Copper metallization
Chemical stability of Ta diffusion barrier between Cu and Si, 64
Creep
Influence of local inhomogeneities on the magnetic properties of thin ferromagnetic films and nanostructures, 107

Diamond
Electrical conductive hard-carbon (diamond-like carbon) films formed by i-C_4H_{10}/N_2 supermagnetron plasma chemical vapor deposition method, 251
Diamond like carbon (DLC)
Characterization of diamond-like carbon (DLC) thin films prepared by r.f. magnetron sputtering, 247
Diamond-like carbon
Effects of the methane content on the characteristics of diamond-like carbon films produced by sputtering, 243
Dielectrics
Ion beam irradiation of thin CaF_2 films: a study of lithographic properties, 46
Diffusion
Structural, optical and electrical characterization of In/CdS/glass thermally annealed system, 10
Diffusion barriers
Chemical stability of Ta diffusion barrier between Cu and Si, 64
DRAM
Fatigue and dielectric properties of the (Pb, La)TiO_3 thin films with various La concentrations, 53

Electrical properties
Electrical and spectroscopic properties of amorphous copper sulfide films treated with iodine, lithium iodide and sodium iodide, 1
Electrical properties and measurements
Intergranular Coulomb barriers in thin films of magnetoresistive manganites, 94
Influence of the microstructure on the magnetoresistance of manganite thin films, 98
Electrical conductive hard-carbon (diamond-like carbon) films

PII: S0040-6090(00)01458-9

formed by i-C_4H_{10}/N_2 supermagnetron plasma chemical vapor deposition method, 251
Electroluminescent device
Manganese-activated gallium oxide electroluminescent phosphor thin films prepared using various deposition methods, 145
Electron-beam lithography
In situ electron-beam processing for III–V semiconductor nanostructure fabrication, 170
Epitaxial
Electrical properties of Ir-silicide formation on p-Si(100) in ultra-high vacuum, 68
Epitaxy
Assessment of a non-linear diffusive–convective model for the ISOVPE MCT growth, 28
Ion beam irradiation of thin CaF_2 films: a study of lithographic properties, 46
ESR
Preparation and characterization of sol–gel glasses containing chromium, 184
Etching rate
Transparent conducting zinc-co-doped ITO films prepared by magnetron sputtering, 189
Ethanol
Influence of Al, In, Cu, Fe and Sn dopants on the response of thin film ZnO gas sensor to ethanol vapour, 137
Evaporation
$(CdTe)_{1-x}(In_2Te_3)_x$ pseudo-binary in polycrystalline CdTe–In films, 23
Electron evaporation of carbon using a high density plasma, 255
Experimental design
Bi–Pb–Sr–Ca–Cu–O/MgO superconducting thin films, 122

Faceted substrate
Growth mode variations of thin films on nano-faceted substrates, 199
Fatigue
Fatigue and dielectric properties of the (Pb, La)TiO_3 thin films with various La concentrations, 53
Ferroelectric
Fatigue and dielectric properties of the (Pb, La)TiO_3 thin films with various La concentrations, 53
Ferroelectrics
Deposition and characterization of PMNT thin films, 60
Ferromagnetic nanostructures
Influence of local inhomogeneities on the magnetic properties of thin ferromagnetic films and nanostructures, 107
Film processing
Bi–Pb–Sr–Ca–Cu–O/MgO superconducting thin films, 122
Film properties
Bi–Pb–Sr–Ca–Cu–O/MgO superconducting thin films, 122
Fluorides
Preparation and properties of precursor Ba–Ca–Cu–(O, F) thin films deposited from fluorides for superconducting Tl- and Hg-based films, 129
Fluorine (fluorides)
Ion beam irradiation of thin CaF_2 films: a study of lithographic properties, 46

Ga_2O_3:Mn
Manganese-activated gallium oxide electroluminescent phosphor thin films prepared using various deposition methods, 145
GaAs
Linear electro-optic reflectance modulated spectra of GaAs (001) around E_1 and $E_1 + \Delta_1$, 207
Gallium arsenide
GaAs surface oxide desorption by annealing in ultra high vacuum, 159
Gas sensors
Influence of Al, In, Cu, Fe and Sn dopants on the response of thin film ZnO gas sensor to ethanol vapour, 137
Germanium
Interfacial reactions of Ti/ and Zr/$Si_{1-x}Ge_x$/Si contacts with rapid thermal annealing, 73
Graded coatings
Ultraviolet-graded coatings for lasers: surface optical performance, 155
Growth mechanism
Assessment of a non-linear diffusive–convective model for the ISOVPE MCT growth, 28
Thickness dependence of the properties of $La_{0.6}Sr_{0.4}MnO_3$ thin films, 102
Growth mode
Growth mode variations of thin films on nano-faceted substrates, 199

Hard coatings
Characterization of diamond-like carbon (DLC) thin films prepared by r.f. magnetron sputtering, 247
Heterostructure-base-transistor
Spectroscopic ellipsometry of Si_xGe_{1-x}/Si: a tool for composition and profile analysis in strained heterostructures used in the microelectronics industry, 211
Heterostructures
Characterization of ZnSe films grown on GaAs substrates with $In_xGa_{1-x}As$ and $Al_xGa_{1-x}As$ buffer layers, 37
Hysteresis
Fatigue and dielectric properties of the (Pb, La)TiO_3 thin films with various La concentrations, 53
Hysteresis loops
Deposition and characterization of PMNT thin films, 60

Ideality factor
Electrical properties of Ir-silicide formation on p-Si(100) in ultra-high vacuum, 68
III–V semiconductor
In situ electron-beam processing for III–V semiconductor nanostructure fabrication, 170
In situ measurements
In situ reflectance difference spectroscopy of p-type ZnTe:N grown by MBE, 41
In situ process
In situ electron-beam processing for III–V semiconductor nanostructure fabrication, 170
Indium
Structural, optical and electrical characterization of In/CdS/glass thermally annealed system, 10
Indium tin oxide
Transparent conducting zinc-co-doped ITO films prepared by magnetron sputtering, 189
Infrared dyes
Organically modified sol–gel films incorporating an infrared dye, 150
Interface
Characterization of ZnSe films grown on GaAs substrates with $In_xGa_{1-x}As$ and $Al_xGa_{1-x}As$ buffer layers, 37
Interfaces
Thickness dependence of the properties of $La_{0.6}Sr_{0.4}MnO_3$ thin films, 102
Ion bombardment
Ion beam irradiation of thin CaF_2 films: a study of lithographic properties, 46
Ion-beam assistance
Boron–carbon–nitrogen compounds grown by ion beam assisted

evaporation, 277
Iridium
Electrical properties of Ir-silicide formation on p-Si(100) in ultra-high vacuum, 68
IrO_2
Formation process and material properties of reactive sputtered IrO_2 thin films, 231
Isothermal vapor phase epitaxy
Assessment of a non-linear diffusive–convective model for the ISOVPE MCT growth, 28

Kinetic Monte Carlo
Growth mode variations of thin films on nano-faceted substrates, 199

Laser ablation
$Ba_{0.5}Sr_{0.5}TiO_3$ thin films deposited by PLD on SiO_2/Si RuO_2/Si and Pt/Si electrodes, 49
Deposition of carbon nitride films by reactive sub-picosecond pulsed laser ablation, 266
Laser mirrors
Ultraviolet-graded coatings for lasers: surface optical performance, 155
Lattice parameters
$(CdTe)_{1-x}(In_2Te_3)_x$ pseudo-binary in polycrystalline CdTe–In films, 23
Lead
Conduction in lead phthalocyanine films with aluminium electrodes, 89
Light scattering
Observation of thermal desorption and MBE growth rate using laser light scattering, 239
Linear electro-optic reflectance
Linear electro-optic reflectance modulated spectra of GaAs (001) around E_1 and $E_1 + \Delta_1$, 207
Local anisotropies
Influence of local inhomogeneities on the magnetic properties of thin ferromagnetic films and nanostructures, 107
Low k dielectrics
Effects of the methane content on the characteristics of diamond-like carbon films produced by sputtering, 243
Luminescence
Optical spectroscopy of near-surface excitonic states, 227

Magnetic properties and measurements
Intergranular Coulomb barriers in thin films of magnetoresistive manganites, 94
Influence of the microstructure on the magnetoresistance of manganite thin films, 98
Thickness dependence of the properties of $La_{0.6}Sr_{0.4}MnO_3$ thin films, 102
Magnetization reversal
Influence of local inhomogeneities on the magnetic properties of thin ferromagnetic films and nanostructures, 107
Magnetization ripple
Influence of local inhomogeneities on the magnetic properties of thin ferromagnetic films and nanostructures, 107
Magnetron sputtering
Transparent conducting zinc-co-doped ITO films prepared by magnetron sputtering, 189
Characterization of diamond-like carbon (DLC) thin films prepared by r.f. magnetron sputtering, 247
Manganese
Intergranular Coulomb barriers in thin films of magnetoresistive manganites, 94
MBE
Observation of thermal desorption and MBE growth rate using laser light scattering, 239
Mercury cadmium telluride
Assessment of a non-linear diffusive–convective model for the ISOVPE MCT growth, 28
Metal-oxide semiconductor structure
Duality metal oxide semiconductor–PN junction in the Al/silicon rich oxide/Si structure as a radiation sensor, 134
Methane
Effects of the methane content on the characteristics of diamond-like carbon films produced by sputtering, 243
Microwave plasma
Microwave plasma characteristics in steel nitriding process, 293
Modelling
Study of morphology of composite films, 203
Molecular beam epitaxy (MBE)
In situ reflectance difference spectroscopy of p-type ZnTe:N grown by MBE, 41
Molecular dynamics
Growth mode variations of thin films on nano-faceted substrates, 199
Molecular-beam epitaxy
Improvement in the crystal quality of ZnSe films on Si(111) substrates with a nitrogen surface treatment, 33
In situ electron-beam processing for III–V semiconductor nanostructure fabrication, 170
Morphological analysis
Study of morphology of composite films, 203
Multilayers
Structure of Ag/Co multilayers on excimer laser irradiation, 216
Structure determination of (Ti,Al)N/Mo multilayers, 287

Nanoaggregates
The growth, structure and optics of CsI–PbI_2 co-evaporated thin films, 195
The growth, structure and optics of CsI–PbI_2 co-evaporated thin films, 195
Nanostructure
In situ electron-beam processing for III–V semiconductor nanostructure fabrication, 170
Nanostructures
Influence of the microstructure on the magnetoresistance of manganite thin films, 98
Nitrides
Deposition of carbon nitride films by reactive sub-picosecond pulsed laser ablation, 266
Boron–carbon–nitrogen compounds grown by ion beam assisted evaporation, 277
Microwave plasma characteristics in steel nitriding process, 293
NVFRAM
Fatigue and dielectric properties of the (Pb, La)TiO_3 thin films with various La concentrations, 53

Optical coatings
Ultraviolet-graded coatings for lasers: surface optical performance, 155
Optical properties
Characterization of ZnSe films grown on GaAs substrates with $In_xGa_{1-x}As$ and $Al_xGa_{1-x}As$ buffer layers, 37
Organically modified sol–gel films incorporating an infrared dye, 150
Preparation and characterization of sol–gel glasses containing chromium, 184
Optical spectroscopy of near-surface excitonic states, 227
Optoelectronic devices
Duality metal oxide semiconductor–PN junction in the Al/silicon

rich oxide/Si structure as a radiation sensor, 134
Oxidation
Characterization of sputtered Ta–Ru thin films for ink-jet heater applications, 84
Oxide phosphor
Manganese-activated gallium oxide electroluminescent phosphor thin films prepared using various deposition methods, 145
Oxides
Intergranular Coulomb barriers in thin films of magnetoresistive manganites, 94
GaAs surface oxide desorption by annealing in ultra high vacuum, 159

Paraelectric
Fatigue and dielectric properties of the (Pb, La)TiO_3 thin films with various La concentrations, 53
PAS spectroscopy
Preparation and characterization of sol–gel glasses containing chromium, 184
Phase diagrams
Chemical stability of Ta diffusion barrier between Cu and Si, 64
Phase transitions
Theoretical study of the structural, electronic and vibrational properties of $CdIn_2Te_4$, 19
Photoluminescence
Preparation and optical properties of Ge and C-induced Ge quantum dots on Si, 164
The growth, structure and optics of CsI–PbI_2 co-evaporated thin films, 195
The growth, structure and optics of CsI–PbI_2 co-evaporated thin films, 195
Photoreflectance measurements
Linear electro-optic reflectance modulated spectra of GaAs (001) around E_1 and $E_1 + \Delta_1$, 207
Phthalocyanine films
Conduction in lead phthalocyanine films with aluminium electrodes, 89
Physical vapor
$(CdTe)_{1-x}(In_2Te_3)_x$ pseudo-binary in polycrystalline CdTe–In films, 23
Plasma processing
Microwave plasma characteristics in steel nitriding process, 293
Plasma processing and deposition
High deposition rate a-Si:H layers from pure SiH_4 and from a 10% dilution of SiH_4 in H_2, 176
Electron evaporation of carbon using a high density plasma, 255
Plasma processing and depostion
Electrical conductive hard-carbon (diamond-like carbon) films formed by *i*-C_4H_{10}/N_2 supermagnetron plasma chemical vapor deposition method, 251
PLT thin film
Fatigue and dielectric properties of the (Pb, La)TiO_3 thin films with various La concentrations, 53
Propane gas sensors
Thin film tin oxide-based propane gas sensors, 141

Quantum dots
Preparation and optical properties of Ge and C-induced Ge quantum dots on Si, 164
In situ electron-beam processing for III–V semiconductor nanostructure fabrication, 170

Raman scattering
Theoretical study of the structural, electronic and vibrational properties of $CdIn_2Te_4$, 19
RBS
Structure determination of (Ti,Al)N/Mo multilayers, 287
Reaction kinetics
The formation of CdTe thin films by the stacked elemental layer method, 15
Reactive sputtering
Formation process and material properties of reactive sputtered IrO_2 thin films, 231
Reflectance difference measurements
Linear electro-optic reflectance modulated spectra of GaAs (001) around E_1 and $E_1 + \Delta_1$, 207
Reflection spec.
In situ reflectance difference spectroscopy of p-type ZnTe:N grown by MBE, 41
Optical spectroscopy of near-surface excitonic states, 227
Resistivity
Characterization of sputtered Ta–Ru thin films for ink-jet heater applications, 84
Formation process and material properties of reactive sputtered IrO_2 thin films, 231
RF reactive magnetron sputtering
Dependency of reactive magnetron-sputtered SiC film quality on the deposition parameters, 180
RF-PECVD
Mechanical properties of boron nitride thin films obtained by RF-PECVD at low temperatures, 273
RHEED
Observation of thermal desorption and MBE growth rate using laser light scattering, 239
Roughness
Structure determination of (Ti,Al)N/Mo multilayers, 287
Ruthenium
Characterization of sputtered Ta–Ru thin films for ink-jet heater applications, 84
Rutherford backscattering
Rutherford backscattering analysis of Bi-based superconducting films, 117

Schottky barrier
Electrical properties of Ir-silicide formation on p-Si(100) in ultra-high vacuum, 68
Self-assembling
Preparation and optical properties of Ge and C-induced Ge quantum dots on Si, 164
Self-organizing growth
In situ electron-beam processing for III–V semiconductor nanostructure fabrication, 170
SEM
Observation of thermal desorption and MBE growth rate using laser light scattering, 239
Semiconductors
Electrical and spectroscopic properties of amorphous copper sulfide films treated with iodine, lithium iodide and sodium iodide, 1
Theoretical study of the structural, electronic and vibrational properties of $CdIn_2Te_4$, 19
$(CdTe)_{1-x}(In_2Te_3)_x$ pseudo-binary in polycrystalline CdTe–In films, 23
In situ reflectance difference spectroscopy of p-type ZnTe:N grown by MBE, 41
Sensors
Duality metal oxide semiconductor–PN junction in the Al/silicon rich oxide/Si structure as a radiation sensor, 134
Si
Improvement in the crystal quality of ZnSe films on Si(111) substrates with a nitrogen surface treatment, 33
SiGeC layers
Preparation and optical properties of Ge and C-induced Ge quan-

tum dots on Si, 164
Silicide
Electrical properties of Ir-silicide formation on p-Si(100) in ultra-high vacuum, 68
Silicides
Interfacial reactions of Ti/ and $Zr/Si_{1-x}Ge_x/Si$ contacts with rapid thermal annealing, 73
Silicon
High deposition rate a-Si:H layers from pure SiH_4 and from a 10% dilution of SiH_4 in H_2, 176
Silicon carbide
Dependency of reactive magnetron-sputtered SiC film quality on the deposition parameters, 180
Silicon oxide
Duality metal oxide semiconductor–PN junction in the Al/silicon rich oxide/Si structure as a radiation sensor, 134
Silicon wafer surfaces
Application of synchrotron radiation to TXRF analysis of metal contamination on silicon wafer surfaces, 222
Silver
Structure of Ag/Co multilayers on excimer laser irradiation, 216
Silver doping
Thin film tin oxide-based propane gas sensors, 141
Size distribution
Study of morphology of composite films, 203
Sol–gel
Organically modified sol–gel films incorporating an infrared dye, 150
Spectroscopic ellipsometry
Spectroscopic ellipsometry of Si_xGe_{1-x}/Si: a tool for composition and profile analysis in strained heterostructures used in the microelectronics industry, 211
Spray pyrolysis
Rutherford backscattering analysis of Bi-based superconducting films, 117
Influence of Al, In, Cu, Fe and Sn dopants on the response of thin film ZnO gas sensor to ethanol vapour, 137
Structural and optical properties of $(ZnO)_x(CdO)_{1-x}$ thin films obtained by spray pyrolysis, 235
Sputtering
The influence of TiB_2-thin film thickness on metal–GaAs structural characteristics, 79
Characterization of sputtered Ta–Ru thin films for ink-jet heater applications, 84
Thickness dependence of the properties of $La_{0.6}Sr_{0.4}MnO_3$ thin films, 102
Stanford Synchrotron Radiation Laboratory
Application of synchrotron radiation to TXRF analysis of metal contamination on silicon wafer surfaces, 222
Stoner–Wohlfarth single domain theory
Influence of local inhomogeneities on the magnetic properties of thin ferromagnetic films and nanostructures, 107
Strained-layer heterostructures
Spectroscopic ellipsometry of Si_xGe_{1-x}/Si: a tool for composition and profile analysis in strained heterostructures used in the microelectronics industry, 211
Structural properties
$Ba_{0.5}Sr_{0.5}TiO_3$ thin films deposited by PLD on SiO_2/Si RuO_2/Si and Pt/Si electrodes, 49
Deposition and characterization of PMNT thin films, 60
The influence of TiB_2-thin film thickness on metal–GaAs structural characteristics, 79
Relation between microstructure and superconducting properties in *a*-axis 123 films and superlattices, 113
Sub-picosecond laser
Deposition of carbon nitride films by reactive sub-picosecond pulsed laser ablation, 266
Sulfides
Electrical and spectroscopic properties of amorphous copper sulfide films treated with iodine, lithium iodide and sodium iodide, 1
Superconducting Bi-based films
Bi–Pb–Sr–Ca–Cu–O/MgO superconducting thin films, 122
Superconductivity
Relation between microstructure and superconducting properties in *a*-axis 123 films and superlattices, 113
Superconductors
Rutherford backscattering analysis of Bi-based superconducting films, 117
Superlattices
Relation between microstructure and superconducting properties in *a*-axis 123 films and superlattices, 113
Surface and interface states
Optical spectroscopy of near-surface excitonic states, 227
Surface morphology
GaAs surface oxide desorption by annealing in ultra high vacuum, 159
Surface treatment
Improvement in the crystal quality of ZnSe films on Si(111) substrates with a nitrogen surface treatment, 33
Synthesis and characterization
Organically modified sol–gel films incorporating an infrared dye, 150

Tantalum
Chemical stability of Ta diffusion barrier between Cu and Si, 64
Characterization of sputtered Ta–Ru thin films for ink-jet heater applications, 84
Thermal annealing
Structural and optical properties of $(ZnO)_x(CdO)_{1-x}$ thin films obtained by spray pyrolysis, 235
Thermal desorption
GaAs surface oxide desorption by annealing in ultra high vacuum, 159
Thermomechanical properties
Mechanical properties of boron nitride thin films obtained by RF-PECVD at low temperatures, 273
Thin film
Manganese-activated gallium oxide electroluminescent phosphor thin films prepared using various deposition methods, 145
Thin Films
Preparation and characterization of sol–gel glasses containing chromium, 184
Transparent conducting zinc-co-doped ITO films prepared by magnetron sputtering, 189
The growth, structure and optics of $CsI–PbI_2$ co-evaporated thin films, 195
The growth, structure and optics of $CsI–PbI_2$ co-evaporated thin films, 195
Deposition of carbon nitride films by reactive sub-picosecond pulsed laser ablation, 266
Tin oxide thin films
Thin film tin oxide-based propane gas sensors, 141
Titanium
Interfacial reactions of Ti/ and $Zr/Si_{1-x}Ge_x/Si$ contacts with rapid thermal annealing, 73
Titanium borides
The influence of TiB_2-thin film thickness on metal–GaAs structural characteristics, 79
$Tl_2Ba_2CaCu_2O_y$ films
Preparation and properties of precursor Ba–Ca–Cu–(O, F) thin films deposited from fluorides for superconducting Tl- and Hg-based films, 129
Total reflection X-ray fluorescence

Application of synchrotron radiation to TXRF analysis of metal contamination on silicon wafer surfaces, 222
Transmission electron microscopy
$Ba_{0.5}Sr_{0.5}TiO_3$ thin films deposited by PLD on SiO_2/Si RuO_2/Si and Pt/Si electrodes, 49
Relation between microstructure and superconducting properties in *a*-axis 123 films and superlattices, 113
Transparent conducting oxide
Transparent conducting zinc-co-doped ITO films prepared by magnetron sputtering, 189
Tungsten
Mechanical and tribological properties of tungsten carbide sputtered coatings, 282

Unfolding process
Study of morphology of composite films, 203

Wear
Mechanical and tribological properties of tungsten carbide sputtered coatings, 282

X-Ray absorption
Boron–carbon–nitrogen compounds grown by ion beam assisted evaporation, 277
X-Ray diffraction
Strain gradients in polycrystalline CdS thin films, 6
$(CdTe)_{1-x}(In_2Te_3)_x$ pseudo-binary in polycrystalline CdTe–In films, 23
$Ba_{0.5}Sr_{0.5}TiO_3$ thin films deposited by PLD on SiO_2/Si RuO_2/Si and Pt/Si electrodes, 49
Preparation and properties of precursor Ba–Ca–Cu–(O, F) thin films deposited from fluorides for superconducting Tl- and Hg-based films, 129
Structure of Ag/Co multilayers on excimer laser irradiation, 216
Structural and optical properties of $(ZnO)_x(CdO)_{1-x}$ thin films obtained by spray pyrolysis, 235
X-ray photoelectron spectroscopy
Formation process and material properties of reactive sputtered IrO_2 thin films, 231
XRD
Structure determination of (Ti,Al)N/Mo multilayers, 287

Zinc oxide
Influence of Al, In, Cu, Fe and Sn dopants on the response of thin film ZnO gas sensor to ethanol vapour, 137
Zirconium
Interfacial reactions of Ti/ and Zr/$Si_{1-x}Ge_x$/Si contacts with rapid thermal annealing, 73
Zn co-doped ITO
Transparent conducting zinc-co-doped ITO films prepared by magnetron sputtering, 189
ZnSe
Improvement in the crystal quality of ZnSe films on Si(111) substrates with a nitrogen surface treatment, 33
Characterization of ZnSe films grown on GaAs substrates with $In_xGa_{1-x}As$ and $Al_xGa_{1-x}As$ buffer layers, 37